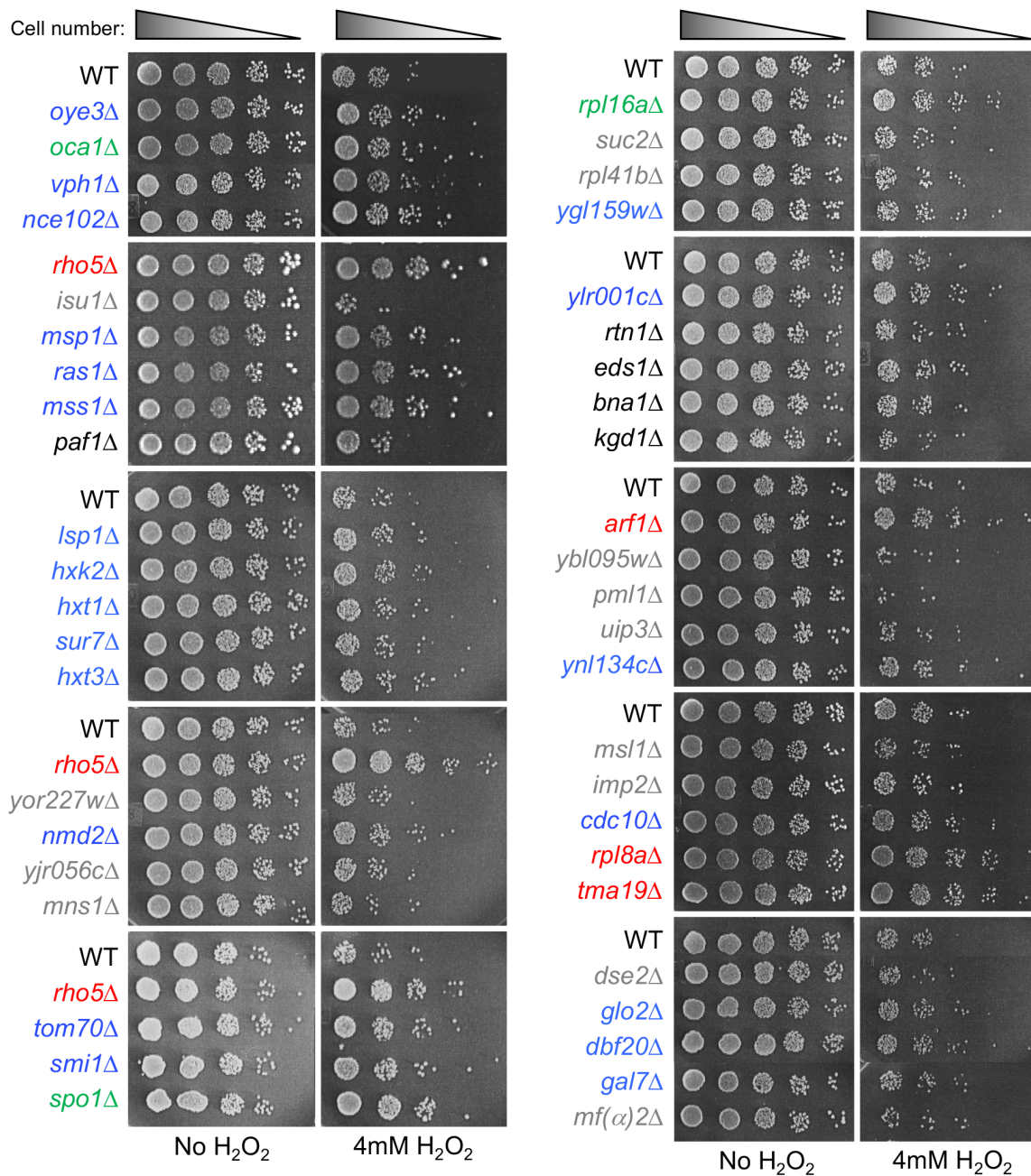
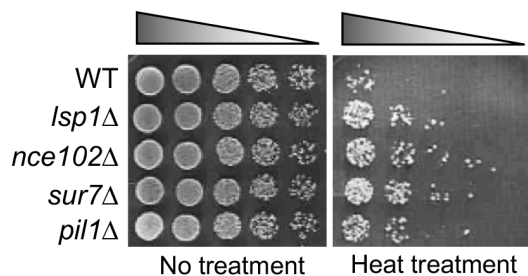


A



B

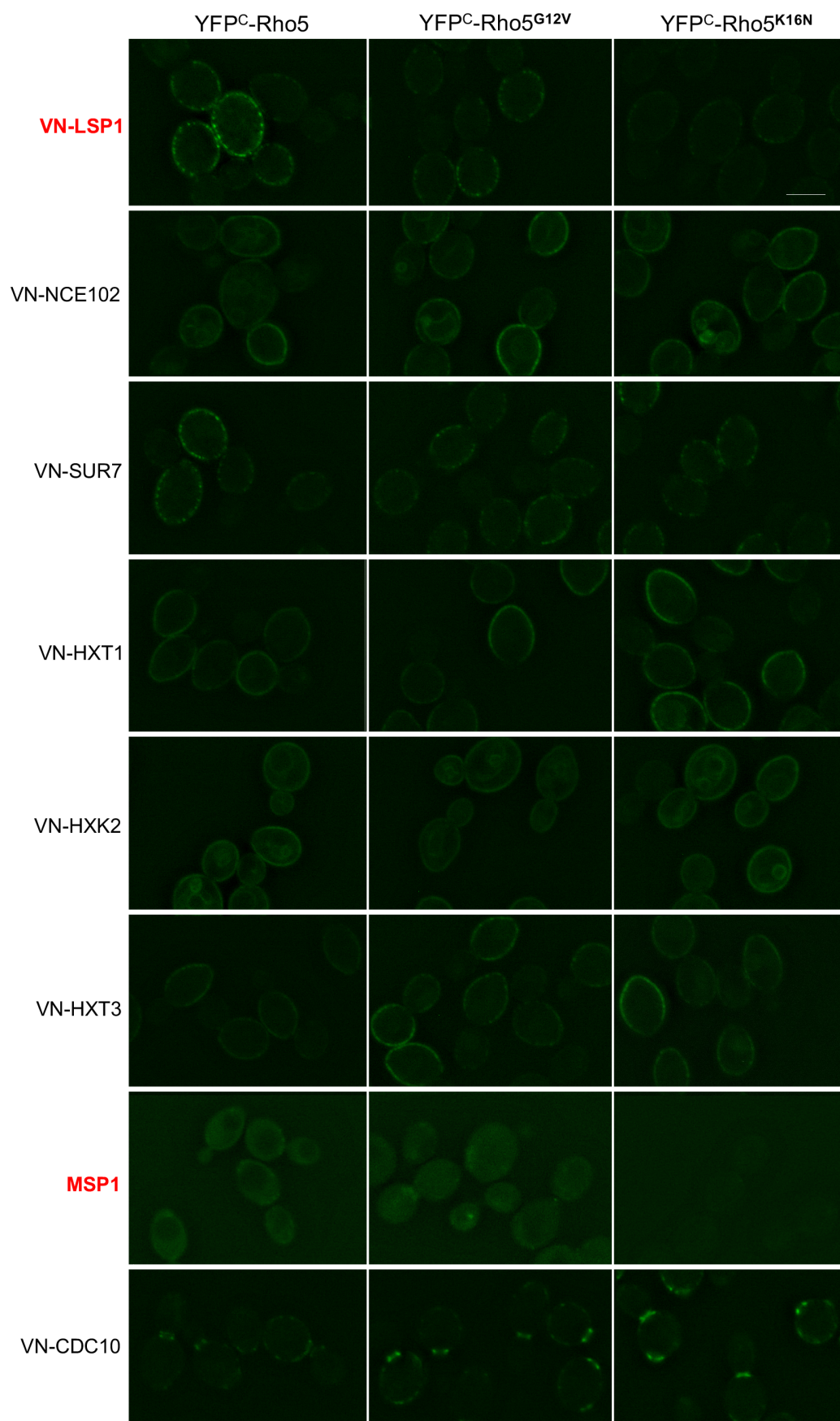


Figures S1. Resistance of selected deletion mutants to H₂O₂

A. Five-fold serial dilutions of each deletion mutant (HPY210 background) were spotted after treatment with 4 mM H₂O₂ for 4 hrs or mock-treatment. Mutants with different degrees of resistance to H₂O₂ are marked in color: strong resistance (similar to *rho5Δ*) in red; medium resistance in green; weak

resistance (slightly more resistant than WT) in blue; and some examples of mutants with similar phenotype as WT in gray.

- B. Cell survival was determined by a 5-fold serial dilution of each strain (BY4741 background) from fresh cultures ($OD_{600} = 0.5\sim 0.6$) after subjecting to heat ramp (right) and without treatment (left) and then grown in YPD plate (see Materials and Methods).



(continued)

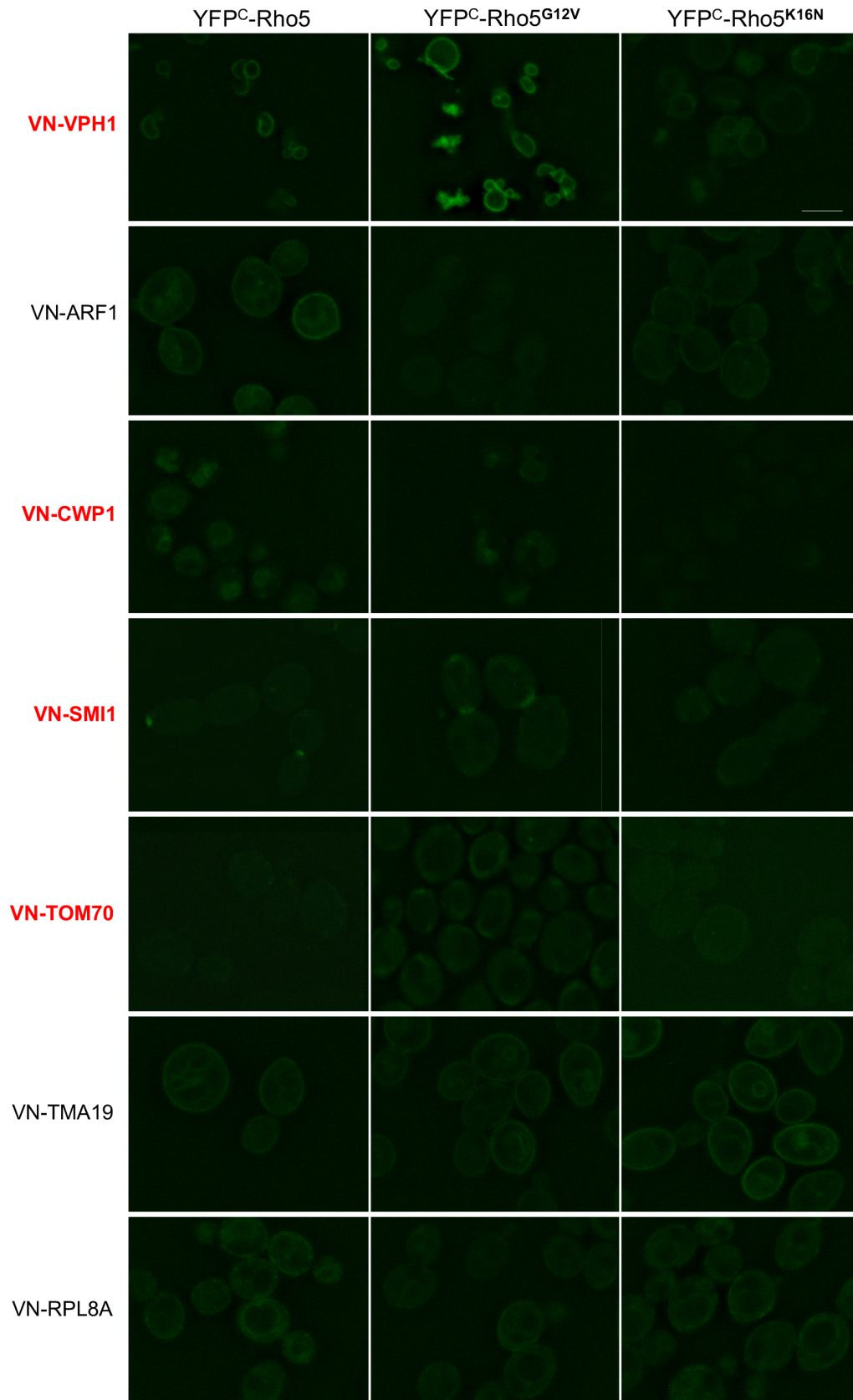


Figure S2. BiFC analyses of candidate VN fusions with YFP^C fusions of WT or mutant Rho5
 Each marked VN fusion was expressed together with YFP^C-Rho5^{WT}, YFP^C-Rho5^{G12V}, or YFP^C-Rho5^{K16N}. Those VN fusions that showed preferentially stronger fluorescence signals with YFP^C-Rho5^{G12V} or YFP^C-Rho5^{WT} are labeled in red.